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May 11, 2018

TO THE ADMINISTRATOR ADDRESSED:

Subject: P-TECH and Industry Cluster Innovative Academy Planning and Designation Applications Open

Applications are now open for Pathways in Technology Early College High School (P-TECH) and Industry Cluster Innovative Academy (ICIA) planning year and designation. The applications are live at http://ccrm.stemcenter.utexas.edu/ and close on May 25, 2018, at 5:00 p.m. Central Standard Time (CST).

Any school district or open-enrollment charter school that would like to start a P-TECH or ICIA program must apply for a planning year with the intent of serving students in the P-TECH or ICIA program beginning in the 2019-2020 school year. Any open enrollment public school district or open-enrollment charter school that is already implementing all the requirements of a P-TECH/ICIA program may apply for 2018-2019 designation as a P-TECH or ICIA school. Recipients of the P-TECH and ICIA Planning or Success grants do not need to complete the applications. A list of P-TECH and ICIA Planning and Success grantee recipients are available here.

Application Technical Assistance

Technical assistance webinars provide information regarding the open applications. Participation is encouraged, not required. Webinars will provide applicants with information regarding how to access and navigate the online, web-based application system. The technical assistance webinars are as follows:

P-TECH and ICIA Planning Year Webinar: Tuesday, May 15, 2018, at 10:00 a.m. CST Register at: https://attendee.gotowebinar.com/register/510362901602657794

P-TECH and ICIA Designation Webinar: Tuesday, May 15, 2018, at 1:00 p.m. CST Register at: https://attendee.gotowebinar.com/register/8482642438653049090

If you have any questions, please contact Stacy Avery, Director, Postsecondary Preparation Programs at ptech@tea.texas.gov.

Sincerely,

Heather Justice Division Director College, Career and Military Preparation